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Atty Docket No. 99-056	Serial No. 09/641,155
Applicant Spencer Wayne Bruce et al.	
Filing Date August 17, 2000	Group 1746

U.S. Patent Documents

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	Class/Subclass	FILING DATE IF APPROPRIATE
<i>PS</i>	AA	5,728,272	03/17/98	Hammon et al.	203/8	
	AB					
	AC					
	AD					
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FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	Class/Subclass	Translation Yes/No
<i>PS</i>	AL	0 248 681 B1	12/16/92	EP		
	AM					
	AN					
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OTHER ART (Including Author, Title, Date, Pertinent Patents, etc.)

<i>PS</i>	AU	CAPLUS 1974:464592, "Removal of Polymer Deposit From Equipment", Nishikawa, Tokutomi; Masuda, Toshihiko, Jan. 25, 1974
	AV	
	AW	

Examiner

Date Considered

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EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	Class/Subclass	FILING DATE IF APPROPRIATE
	AA	5,782,989	07/21/98	Rueter	134/22.19	
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TC 1702 MAIL ROOM

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JAN 31 2001**FOREIGN PATENT DOCUMENTS**

		DOCUMENT NUMBER	DATE	COUNTRY	Class/Subclass	Translation Yes/No
	AL	DE 33 25 166 A1	1/24/95	DE		Yes
	AM					
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